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(54) Title: CLEANING SYSTEM UTILIZING AN ORGANIC CLEANING SOLVENT AND A PRESSURIZED FLUID SOLVENT

(57) Abstract: A cleaning system that utilizes an organic cleaning solvent and pressurized fluid solvent is disclosed. The system has no conventional evaporative hot air drying cycle. Instead, the system utilizes the solubility of the organic solvent in pressurized fluid solvent as well as the physical properties of pressurized fluid solvent. After an organic solvent cleaning cycle, the solvent is extracted from the textiles at high speed in a rotating drum in the same way conventional solvents are extracted from textiles in conventional evaporative hot air dry cleaning machines. Instead of proceeding to a conventional drying cycle, the extracted textiles are then immersed in pressurized fluid solvent to extract the residual organic solvent from the textiles. This is possible because the organic solvent is soluble in pressurized fluid solvent. After the textiles are immersed in pressurized fluid solvent, pressurized fluid solvent is pumped from the drum. Finally, the drum is de-pressurized to atmospheric pressure to evaporate any remaining pressurized fluid solvent, yielding clean, solvent free textiles. The organic solvent is preferably dipropylene glycol n-butyl ether, tripropylene glycol n-butyl ether or tripropylene glycol methyl ether, a mixture thereof, or a similar solvent and the pressurized fluid solvent is preferably densified carbon dioxide.

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CLEANING SYSTEM UTILIZING AN ORGANIC CLEANING SOLVENT AND A PRESSURIZED FLUID SOLVENT

BACKGROUND

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Field of the Invention

The present invention relates generally to cleaning systems, and more specifically to substrate cleaning systems, such as textile cleaning systems, utilizing an organic cleaning solvent and a pressurized fluid solvent.

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Related Art

A variety of methods and systems are known for cleaning substrates such as textiles, as well as other flexible, precision, delicate, or porous structures that are sensitive to soluble and insoluble contaminants. These known methods and systems typically use water, perchloroethylene, petroleum, and other solvents that are liquid at or substantially near atmospheric pressure and room temperature for cleaning the substrate.

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Such conventional methods and systems generally have been considered satisfactory for their intended purpose. Recently, however, the desirability of employing these conventional methods and systems has been questioned due to environmental, hygienic, occupational hazard, and waste disposal concerns, among other things. For example, perchloroethylene frequently is used as a solvent to clean delicate substrates, such as textiles, in a process referred to as "dry cleaning." Some locales require that the use and disposal of this solvent be regulated by environmental agencies, even when only trace amounts of this solvent are to be introduced into waste streams.

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Furthermore, there are significant regulatory burdens placed on solvents such as perchloroethylene by agencies such as the EPA, OSHA and DOT. Such regulation results in increased costs to the user, which, in turn, are passed to the ultimate consumer. For example, filters that have been used in conventional perchloroethylene dry cleaning systems must be disposed of in accordance with hazardous waste or other environmental regulations. Certain other solvents used in

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dry cleaning, such as hydrocarbon solvents, are extremely flammable, resulting in greater occupational hazards to the user and increased costs to control their use.

In addition, textiles that have been cleaned using conventional cleaning methods are typically dried by circulating hot air through the textiles as they are
5 tumbled in a drum. The solvent must have a relatively high vapor pressure and low boiling point to be used effectively in a system utilizing hot air drying. The heat used in drying may permanently set some stains in the textiles. Furthermore, the drying cycle adds significant time to the overall processing time. During the conventional drying process, moisture adsorbed on the textile fibers is often removed in addition
10 to the solvent. This often results in the development of undesirable static electricity and shrinkage in the garments. Also, the textiles are subject to greater wear due to the need to tumble the textiles in hot air for a relatively long time. Conventional drying methods are inefficient and often leave excess residual solvent in the textiles, particularly in heavy textiles, components constructed of multiple fabric layers, and
15 structural components of garments such as shoulder pads. This may result in unpleasant odors and, in extreme cases, may cause irritation to the skin of the wearer. In addition to being time consuming and of limited efficiency, conventional drying results in significant loss of cleaning solvent in the form of fugitive solvent vapor. Finally, conventional hot air drying is an energy intensive process that results
20 in relatively high utility costs and accelerated equipment wear.

Traditional cleaning systems may utilize distillation in conjunction with filtration and adsorption to remove soils dissolved and suspended in the cleaning solvent. The filters and adsorptive materials become saturated with solvent, therefore, disposal of some filter waste is regulated by state or federal laws. Solvent
25 evaporation especially during the drying cycle is one of the main sources of solvent loss in conventional systems. Reducing solvent loss improves the environmental and economic aspects of cleaning substrates using cleaning solvents. It is therefore advantageous to provide a method and system for cleaning substrates that utilizes a solvent having less adverse attributes than those solvents currently used and that
30 reduces solvent losses.

As an alternative to conventional cleaning solvents, pressurized fluid solvents or densified fluid solvents have been used for cleaning various substrates, wherein densified fluids are widely understood to encompass gases that are pressurized to either subcritical or supercritical conditions so as to achieve a liquid or a supercritical
5 fluid having a density approaching that of a liquid. In particular, some patents have disclosed the use of a solvent such as carbon dioxide that is maintained in a liquid state or either a subcritical or supercritical condition for cleaning such substrates as textiles, as well as other flexible, precision, delicate, or porous structures that are sensitive to soluble and insoluble contaminants.

10 For example, U.S. Patent No. 5,279,615 discloses a process for cleaning textiles using densified carbon dioxide in combination with a non-polar cleaning adjunct. The preferred adjuncts are paraffin oils such as mineral oil or petrolatum. These substances are a mixture of alkanes including a portion of which are C₁₆ or higher hydrocarbons. The process uses a heterogeneous cleaning system formed
15 by the combination of the adjunct which is applied to the textile prior to or substantially at the same time as the application of the densified fluid. According to the data disclosed in Patent No. 5,279,615, the cleaning adjunct is not as effective at removing soil from fabric as conventional cleaning solvents or as the solvents described for use in the present invention as disclosed below.

20 U.S. Patent No. 5,316,591 discloses a process for cleaning substrates using liquid carbon dioxide or other liquefied gases below their critical temperature. The focus of this patent is on the use of any one of a number of means to effect ultrasonic cavitation to enhance the cleaning performance of the liquid carbon dioxide. In all of the disclosed embodiments, densified carbon dioxide is the cleaning
25 medium. This patent does not describe the use of a solvent other than the liquefied gas for cleaning substrates. While the combination of ultrasonic cavitation and liquid carbon dioxide may be well suited to processing complex hardware and substrates containing extremely hazardous contaminants, this process is too costly for the regular cleaning of textile substrates. Furthermore, the use of ultrasonic cavitation is
30 less effective for removing contaminants from textiles than it is for removing contaminants from hard surfaces.

U.S. Patent No. 5,377,705 discloses a process for cleaning precision parts utilizing a liquefied pressurized gas in the supercritical state and an environmentally acceptable co-solvent. During this process, the parts to be cleaned are pre-treated with the co-solvent and then placed in the cleaning vessel. Afterwards, the

5 contaminants and co-solvent are removed from the parts by circulating a pressurized gas in its supercritical state through the vessel. Redeposition of co-solvent and contaminants is controlled by the amount of pressurized gas that is pumped through the vessel. Co-solvents specified for use in conjunction with the cleaning solvent include aliphatics, terpenes, acetone, laminines, isopropyl alcohol, Axarel (DuPont),

10 Petroferm (Petroferm, Inc.), kerosene, and Isopar-m (Exxon). During the cleaning process, the cleaning solvent (supercritical carbon dioxide) flows through a vessel containing the parts to be treated, through a filter or filters and directly to a separator in which the solvent is evaporated and recondensed. The disclosed co-solvents for use in this patent have high evaporation rates and low flash points. The use of such

15 co-solvents results in high solvent losses, and high fire risks. Furthermore, many of the co-solvents are not compatible with common dyes and fibers used in textile manufacture. Also, the use of supercritical carbon dioxide necessitates the use of more expensive equipment.

U.S. Patent No. 5,417,768 discloses a process for precision parts cleaning

20 using a two-solvent system. One solvent can be liquid at room temperature and pressure while the second solvent can be supercritical carbon dioxide. The objectives of this invention include using two or more solvents with minimal mixing of the solvents and to incorporate ultrasonic cavitation in such a way as to prevent the ultrasonic transducers from coming in contact with the first-mentioned solvent. An

25 apparatus is described which consists of an open top vessel within a covered pressurized vessel. The primary fluid is pumped into the open top vessel. After cleaning with the primary fluid, it is pumped from the open top vessel. Pressurized carbon dioxide is then pumped into the open top vessel and flushed through the vessel until the level of contaminants within the vessel are reduced to the desired

30 level. The co-solvents disclosed in this patent are the same solvents specified in

U.S. Patent No. 5,377,705. Use of these solvents would introduce a high risk of fire, high levels of solvent loss and potential damage to a wide range of textiles.

U.S. Patent No. 5,888,250 discloses the use of a binary azeotrope comprised of propylene glycol tertiary butyl ether and water as an environmentally attractive replacement for perchlorethylene in dry cleaning and degreasing processes. While the use of propylene glycol tertiary butyl ether is attractive from an environmental regulatory point of view, its use as disclosed in this invention is in a conventional dry cleaning process using conventional dry cleaning equipment and a conventional evaporative hot air drying cycle. As a result, it has many of the same disadvantages as conventional dry cleaning processes described above.

Several of the pressurized fluid solvent cleaning methods described in the above patents may lead to recontamination of the substrate and degradation of cleaning efficiency because the contaminated solvent is not continuously purified or removed from the system. Furthermore, pressurized fluid solvent alone is not as effective at removing some types of soil as are conventional cleaning solvents. Consequently, pressurized fluid solvent cleaning methods require individual treatment of stains and heavily soiled areas of textiles, which is a labor-intensive process. Furthermore, systems that utilize pressurized fluid solvents for cleaning are more expensive and complex to manufacture and maintain than conventional cleaning systems. Finally, few if any conventional surfactants can be used effectively in pressurized fluid solvents. The surfactants and additives that can be used in pressurized fluid solvent cleaning systems are much more expensive than those used in conventional cleaning systems.

There thus remains a need for an efficient and economic method and system for cleaning substrates that incorporates the benefits of prior systems, and minimizes the difficulties encountered with each. There also remains a need for a method and system in which the hot air drying time is eliminated, or at least reduced, thereby reducing the wear on the substrate and preventing stains from being permanently set on the substrate.

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SUMMARY

In the present invention, certain types of organic solvents, such as glycol ethers and, specifically, poly glycol ethers including dipropylene glycol n-butyl ether, tripropylene glycol n-butyl ether or tripropylene glycol methyl ether, or similar
5 solvents or mixtures of such solvents are used. Any type of organic solvent that falls within the chemical formulae disclosed hereinafter may be used. However, unlike conventional cleaning systems, in the present invention, a conventional drying cycle is not necessary. Instead, the system utilizes the solubility of the organic solvent in pressurized fluid solvents, as well as the physical properties of pressurized fluid
10 solvents, to dry the substrate being cleaned.

As used herein, the term "pressurized fluid solvent" refers to both pressurized liquid solvents and densified fluid solvents. The term "pressurized liquid solvent" as used herein refers to solvents that are preferably liquid at between approximately 600 and 1050 pounds per square inch and between approximately 5 and 30 degrees
15 Celsius, but are gas at atmospheric pressure and room temperature. The term "densified fluid solvent" as used herein refers to a gas or gas mixture that is compressed to either subcritical or supercritical conditions so as to achieve either a liquid or a supercritical fluid having density approaching that of a liquid. Preferably, the pressurized fluid solvent used in the present invention is an inorganic substance
20 such as carbon dioxide, xenon, nitrous oxide, or sulfur hexafluoride. Most preferably, the pressurized fluid solvent is densified carbon dioxide.

The substrates are cleaned in a perforated drum within a vessel in a cleaning cycle using an organic solvent. A perforated drum is preferred to allow for free interchange of solvent between the drum and vessel as well as to transport soil from
25 the substrates to the filter. After substrates have been cleaned in the perforated drum, the organic solvent is extracted from the substrates by rotating the cleaning drum at high speed within the cleaning vessel in the same way conventional solvents are extracted from substrates in conventional cleaning machines. However, instead of proceeding to a conventional evaporative hot air drying cycle, the substrates are
30 immersed in pressurized fluid solvent to extract the residual organic solvent from the substrates. This is possible because the organic solvent is soluble in the pressurized

fluid solvent. After the substrates are immersed in pressurized fluid solvent, which may also serve as a cleaning solvent, the pressurized fluid solvent is transferred from the drum. Finally, the vessel is de-pressurized to atmospheric pressure to evaporate any remaining pressurized fluid solvent, yielding clean, solvent-free
5 substrates.

Glycol ethers, specifically poly glycol ethers, used in the present invention tend to be soluble in pressurized fluid solvents such as supercritical or subcritical carbon dioxide so that a conventional hot air drying cycle is not necessary. The types of poly glycol ethers used in conventional cleaning systems must have a
10 reasonably high vapor pressure and a low boiling point because they must be removed from the substrates by evaporation in a stream of hot air. However, solvents, particularly non-halogenated solvents, that have a high vapor pressure and a low boiling point generally also have a low flash point. From a safety standpoint, organic solvents used in cleaning substrates should have a flash point that is as high
15 as possible, or preferably, it should have no flash point. By eliminating the conventional hot air evaporative drying process, a wide range of solvents can be used in the present invention that have much lower evaporation rates, higher boiling points and higher flash points than those used in conventional cleaning systems.

Thus, the cleaning system described herein utilizes solvents that are less
20 regulated and less combustible, and that efficiently remove different soil types typically deposited on textiles through normal use. The cleaning system reduces solvent consumption and waste generation as compared to conventional dry cleaning systems. Machine and operating costs are reduced as compared to currently used pressurized fluid solvent systems, and conventional additives may be
25 used in the cleaning system.

Furthermore, one of the main sources of solvent loss from conventional dry cleaning systems, which occurs in the evaporative hot air drying step, is eliminated altogether. Because the conventional evaporative hot air drying process is eliminated, there are no heat set stains on the substrates, risk of fire and/or
30 explosion is reduced, the total cycle time is reduced, and residual solvent in the substrates is substantially reduced or eliminated. Substrates are also subject to less

wear, less static electricity build-up and less shrinkage because there is no need to tumble the substrates in a stream of hot air to dry them.

While systems according to the present invention utilizing pressurized fluid solvent to remove organic solvent can be constructed as wholly new systems, existing conventional solvent systems can also be converted to utilize the present invention. An existing conventional solvent system can be used to clean substrates with organic solvent, and an additional pressurized chamber for drying substrates with pressurized fluid solvent can be added to the existing system.

Therefore, according to the present invention, textiles are cleaned by placing the textiles to be cleaned into a cleaning drum within a cleaning vessel, adding an organic solvent to the cleaning vessel, cleaning the textiles with the organic solvent, removing a portion of the organic solvent from the cleaning vessel, rotating the cleaning drum to extract a portion of the organic solvent from the textiles, placing the textiles into a drying drum within a pressurizable drying vessel, adding a pressurized fluid solvent to the drying vessel, removing a portion of the pressurized fluid solvent from the drying vessel, rotating the drying drum to extract a portion of the pressurized fluid solvent from the textiles, depressurizing the drying vessel to remove the remainder of the pressurized fluid solvent by evaporation, and removing the textiles from the depressurized vessel.

These and other features and advantages of the invention will be apparent upon consideration of the following detailed description of the presently preferred embodiment of the invention, taken in conjunction with the claims and appended drawings, as well as will be learned by practice of the invention.

BRIEF DESCRIPTION OF THE DRAWINGS

FIG. 1 is a block diagram of a cleaning system utilizing separate vessels for cleaning and drying.

FIG. 2 is a block diagram of a cleaning system utilizing a single vessel for cleaning and drying.

DETAILED DESCRIPTION

Reference will now be made in detail to embodiments of the invention, examples of which are illustrated in the accompanying drawings. The steps of each method for cleaning and drying a substrate will be described in conjunction with the
5 detailed description of the system.

The methods and systems presented herein may be used for cleaning a variety of substrates. The present invention is particularly suited for cleaning substrates such as textiles, as well as other flexible, precision, delicate, or porous structures that are sensitive to soluble and insoluble contaminants. The term "textile"
10 is inclusive of, but not limited to, woven or non-woven materials, as well as articles therefrom. Textiles include, but are not limited to, fabrics, articles of clothing, protective covers, carpets, upholstery, furniture and window treatments. For purposes of explanation and illustration, and not limitation, exemplary embodiments of a system for cleaning textiles in accordance with the invention are shown in FIGS.
15 1 and 2.

As noted above, the pressurized fluid solvent used in the present invention is either a pressurized liquid solvent or a densified fluid solvent. Although a variety of solvents may be used, it is preferred that an inorganic substance such as carbon dioxide, xenon, nitrous oxide, or sulfur hexafluoride, be used as the pressurized fluid
20 solvent. For cost and environmental reasons, liquid, supercritical, or subcritical carbon dioxide is the preferred pressurized fluid solvent.

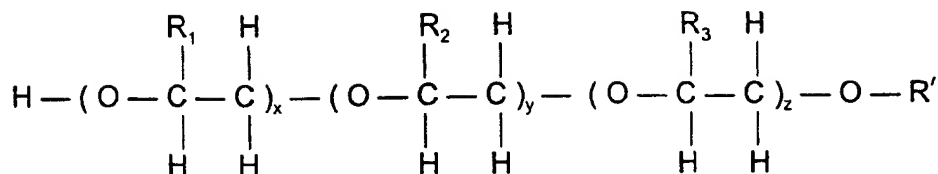
Furthermore, to maintain the pressurized fluid solvent in the appropriate fluid state, the internal temperature and pressure of the system must be appropriately controlled relative to the critical temperature and pressure of the pressurized fluid
25 solvent. For example, the critical temperature and pressure of carbon dioxide is approximately 31 degrees Celsius and approximately 73 atmospheres, respectively. The temperature may be established and regulated in a conventional manner, such as by using a heat exchanger in combination with a thermocouple or similar regulator to control temperature. Likewise, pressurization of the system may be performed
30 using a pressure regulator and a pump and/or compressor in combination with a

pressure gauge. These components are conventional and are not shown in FIGS. 1 and 2 as placement and operation of these components are known in the art.

The system temperature and pressure may be monitored and controlled either manually, or by a conventional automated controller (which may include, for
5 example, an appropriately programmed computer or appropriately constructed microchip) that receives signals from the thermocouple and pressure gauge, and then sends corresponding signals to the heat exchanger and pump and/or compressor, respectively. Unless otherwise noted, the temperature and pressure is appropriately maintained throughout the system during operation. As such,
10 elements contained within the system are constructed of sufficient size and material to withstand the temperature, pressure, and flow parameters required for operation, and may be selected from, or designed using, any of a variety of presently available high pressure hardware.

In the present invention, the preferred organic solvent should have a flash
15 point of greater than 200°F to allow for increased safety and less governmental regulation, have a low evaporation rate to minimize fugitive emissions, be able to remove soils consisting of insoluble particulate soils and solvent soluble oils and greases, and prevent or reduce redeposition of soil onto the textiles being cleaned. Preferably, the organic solvent in the present invention is a glycol ether, and
20 specifically a poly glycol ether such as dipropylene glycol n-butyl ether, tripropylene glycol n-butyl ether or tripropylene glycol methyl ether, or any combination of two or more of these. A description of the chemical formulae of the organic solvents that can be used in the cleaning processes of the invention follows. As used herein, elemental designations are the same as used by one of skill in the art. For example,
25 as used herein, H designates hydrogen, O designated oxygen, C designates carbon, S designates sulfur, Si designates silicon, CH₃ designates methyl, CH₂CH₃ designates ethyl, and R is a variable that designates a chemical structure as described further herein.

In one embodiment of the invention, the organic solvent of the invention is
30 composed, in part, of a glycol ether having a structure of:

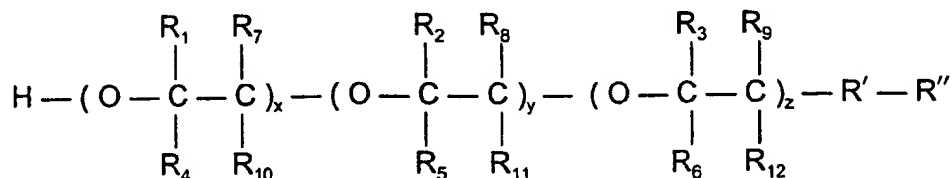


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General Chemical Structure A

A complete description of the glycol ether compounds that fall within the generic structure above and that fulfill the functional parameters of the invention takes into account some variability in the number of subunits identified by subscripts "x", "y" and "z". Subscripts "x", "y" and "z" can each be either zero or one and each of their values is independent of the value of the other two subscripts. That is, the subscripts can have values different from each other. However, at least one of "x", "y" or "z" is one. Group R' has the structure of a straight-chain or branched alkyl group; that is a structure of C_jH_{2j+1}. Subscript value "j" is an integer ranging from one and the value of the difference calculated by 13-3(x+y+z). Because at least one of "x", "y" and "z" must always have the value of 1, "j" has a value ranging from 4 to 10. Groups R₁, R₂ and R₃ are each independently either H or CH₃. The identities of R₁, R₂ and R₃ are selected independent of each other; therefore, R₁ and R₂ can be H while R₃ is CH₃. The types of glycol ether compounds that are encompassed by this chemical structure include, but are not limited to, mono and polyethylene and propylene glycol aliphatic ethers.

Another group of organic solvent compositions that can be used in the cleaning processes of the invention include solvents that can be described as having the chemical structure of:



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General Chemical Structure B

As with the organic solvents characterized by the Chemical Structure A, the subscripts "x", "y" and "z" can each be either zero or one and each of their values is independent of the value of the other two subscripts. That is, the subscripts can have values different from each other. However, at least one of "x", "y" or "z" is one. Group R'' has the structure of benzyl, phenyl, their fluorinated and partially fluorinated analogues, C_jH_{2j+1} , or $C_jH_xF_y$. Subscript value "j" is an integer ranging from one and the value of the difference calculated by $13-3(x+y+z)$. Subscript values "a" and "b" range from zero to $2j+1$; and $a+b=2j+1$. Because at least one of "x", "y" and "z" must always have the value of 1, "j" has a value ranging from 4 to 10. Group R' can be any one of an O, S, carbonyl or ester groups. Lastly, R_{1-12} have a general formula of $C_mH_nF_p$ or $C_dH_eF_g$. The subscripts "m", "n" and "p" have the values described as follows: "m" is an integer ranging from zero to two; "n" and "p" are integers ranging from zero to five; and $n+p=2m+1$. The subscripts "d", "e" and "g" have the values described as follows: "d" is an integer ranging from zero to two; "e" and "g" are integers ranging from zero to five; and $e+g=2d+1$. The types of glycol ether compounds that are encompassed by this chemical structure include, but are not limited to, aromatic, aliphatic, and fluorinated and partially fluorinated, aliphatic and aromatic mono and poly glycol ethers and thioethers, and carbonyl and ester derivatives thereof.

The General Chemical Structure B described above can also be broken down further into various subgroups, as is shown in Table 1 below.

| TABLE 1 | | | | | | |
|-----------|--|-----------|-----------|-------------|----------------------|---------------|
| Sub-group | R_{1-3} | R_{4-6} | R_{7-9} | R_{10-12} | R' | R'' |
| B1 | H or CH_3 | H | H | H | O | C_jH_{2j+1} |
| B2 | H or CH_3 | H | H | H | S, carbonyl or ester | C_jH_{2j+1} |
| B3 | H, CH_3 , or C_2H_5 , and at least one is CH_2CH_3 | H | H | H | O | C_jH_{2j+1} |

TABLE 1

| Sub-group | R ₁₋₃ | R ₄₋₆ | R ₇₋₉ | R ₁₀₋₁₂ | R' | R'' |
|-----------|---|------------------|------------------|---|-----------------------|--|
| B4 | H, CH ₃ , or C ₂ H ₅ , and at least one is CH ₂ CH ₃ | H | H | H | S, carbonyl or ester | C _j H _{2j+1} |
| B5 | H | H | H | H or CH ₃ and at least one is CH ₃ | O | C _j H _{2j+1} |
| B6 | H | H | H | H or CH ₃ and at least one is CH ₃ | S, carbonyl or ester | C _j H _{2j+1} |
| B7 | H | H | H | H, CH ₃ , or C ₂ H ₅ , and at least one is CH ₂ CH ₃ | O | C _j H _{2j+1} |
| B8 | H | H | H | H, CH ₃ , or C ₂ H ₅ , and at least one is CH ₂ CH ₃ | S, carbonyl or ester | C _j H _{2j+1} |
| B9 | H, F, CH ₃ , CH ₂ F, CHF ₂ , or CF ₃ and at least one is CH ₃ , CH ₂ F, CHF ₂ , or CF ₃ | H or F | H or F | H or F | O | C _j H _a F _b |
| B10 | H, F, CH ₃ , CH ₂ F, CHF ₂ , or CF ₃ and at least one is CH ₃ , CH ₂ F, CHF ₂ , or CF ₃ | H or F | H or F | H or F | S, carbonyl, or ester | C _j H _a F _b |
| B11 | C _m H _n F _p and at least one is C ₂ H _n F _p | H or F | H or F | H or F | O | C _j H _a F _b |
| B12 | C _m H _n F _p and at least one is C ₂ H _n F _p | H or F | H or F | H or F | S, carbonyl or ester | C _j H _a F _b |
| B13 | H or F | H or F | H or F | H, F, CH ₃ , CH ₂ F, CHF ₂ or CF ₃ and at least one is CH ₃ , CH ₂ F, CHF ₂ or CF ₃ | O | C _j H _a F _b |

TABLE 1

| Sub-group | R _{1,3} | R _{4,6} | R _{7,9} | R ₁₀₋₁₂ | R' | R'' |
|-----------|---|------------------|------------------|---|-----------------------|--|
| B14 | H or F | H or F | H or F | H, F, CH ₃ , CH ₂ F, CHF ₂ or CF ₃ and at least one is CH ₃ , CH ₂ F, CHF ₂ or CF ₃ | S, carbonyl or ester | C _i H _a F _b |
| B15 | C _m H _n F _p | H or F | H or F | C _d H _e F _g | O | C _i H _a F _b |
| B16 | C _m H _n F _p | H or F | H or F | C _d H _e F _g | S, carbonyl, or ester | C _i H _a F _b |
| B17 | H, CH ₃ , or C ₂ H ₅ , and at least one is CH ₂ CH ₃ | H | H | H | O | benzyl or phenyl |
| B18 | H, CH ₃ , or C ₂ H ₅ , and at least one is CH ₂ CH ₃ | H | H | H | S, carbonyl or ester | benzyl or phenyl |
| B19 | H | H | H | H or CH ₃ and at least one is CH ₃ | O | benzyl or phenyl |
| B20 | H | H | H | H or CH ₃ and at least one is CH ₃ | S, carbonyl or ester | benzyl or phenyl |
| B21 | H | H | H | H, CH ₃ , or C ₂ H ₅ , and at least one is CH ₂ CH ₃ | O | benzyl or phenyl |
| B22 | H | H | H | H, CH ₃ , or C ₂ H ₅ , and at least one is CH ₂ CH ₃ | S, carbonyl or ester | benzyl or phenyl |
| B23 | C _m H _n F _p and at least one is C ₂ H _n F _p | H or F | H or F | H or F | O | benzyl, phenyl, or fluorinated or partially fluorinated benzyl or phenyl |
| B24 | C _m H _n F _p and at least one is C ₂ H _n F _p | H or F | H or F | H or F | S, carbonyl or ester | benzyl, phenyl, or fluorinated or partially fluorinated benzyl or phenyl |

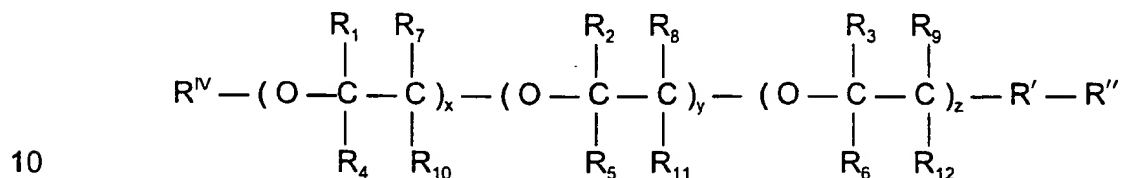
| TABLE 1 | | | | | | |
|-----------|--|------------------|------------------|---|----------------------|--|
| Sub-group | R ₁₋₃ | R ₄₋₆ | R ₇₋₉ | R ₁₀₋₁₂ | R' | R'' |
| B25 | H or F | H or F | H or F | H, F, CH ₃ , CH ₂ F, CHF ₂ or CF ₃ and at least one is CH ₃ , CH ₂ F, CHF ₂ or CF ₃ | O | benzyl, phenyl or fluorinated or partially fluorinated benzyl or phenyl |
| B26 | H or F | H or F | H or F | H, F, CH ₃ , CH ₂ F, CHF ₂ or CF ₃ and at least one is CH ₃ , CH ₂ F, CHF ₂ or CF ₃ | S, carbonyl or ester | benzyl, phenyl, or fluorinated or partially fluorinated benzyl or phenyl |
| B27 | H or F | H or F | H or F | C _m H _n F _p and at least one is C ₂ H _n F _p | O | benzyl, phenyl, or fluorinated or partially fluorinated benzyl or phenyl |
| B28 | H or F | H or F | H or F | C _m H _n F _p and at least one is C ₂ H _n F _p | S, carbonyl or ester | benzyl, phenyl, or fluorinated or partially fluorinated benzyl or phenyl |
| B29 | C _m H _n F _p | H or F | H or F | C _d H _e F _g | O | benzyl, phenyl, or fluorinated or partially fluorinated benzyl or phenyl |
| B30 | C _m H _n F _p | H or F | H or F | C _d H _e F _g | S, carbonyl or ester | benzyl, phenyl, or fluorinated or partially fluorinated benzyl or phenyl |

5 In each of the groups described in Table 1 above, R₁₋₁₂ are grouped together as R₁₋₃, R₄₋₆, R₇₋₉, and R₁₀₋₁₂ for ease of description. Where the individual components of a

10 group can be different elements, the elements are described in the chart in the alternative. For example, R₁₋₃ may be described as "H or F." In a given solvent compound with this description, each of R₁, R₂ and R₃ may be H or each of R₁, R₂ and R₃ may be F. Alternatively, R₁ and R₂ may be H while R₃ is F, and so forth with

the various combinations of "H" and "F". This is the same throughout the Tables in this specification.

Another group of organic solvent compositions that can be used in the cleaning processes of the invention include solvents that can be described as having the chemical structure of:



General Chemical Structure C

In General Chemical Structure C, subscripts "x", "y" and "z" each have a value of either zero or one, but at least one of "x", "y" and "z" has a value of one. Group R' has a structure of C_jH_{2j+1} or $C_jH_uF_v$ and group R^{IV} has a structure of C_kH_{2k+1} or $C_kH_rF_s$. The values of subscripts "j" and "k" are integers ranging from one and the value of $13-3(x+y+z)$. Therefore, subscripts "j" and "k" can have integer values ranging from one and a maximum value of 10 (if two of "x", "y" and "z" are zero). Further, the sum, $j+k$ is an integer ranging from two and the value of $13-3(x+y+z)$. The subscripts "u" and "v" are integers ranging from zero to $2j+1$; and $u+v=2j+1$. The subscripts "r" and "s" are integers ranging from zero to $2k+1$; and $r+s=2k+1$.

In further defining General Chemical Structure C, groups R_{1-3} and R_{10-12} can be hydrogen ("H"), fluorine ("F"), methyl ("CH₃"), ethyl ("CH₂CH₃"), or partially or fully fluorinated methyl or ethyl groups. Each one of R_{1-3} and R_{10-12} are selected independently of each other so as to achieve various combinations of the above as contemplated by the invention. Generally, R_{1-3} have the formula of $C_mH_nF_p$. The subscripts "m", "n" and "p" have the values described as follows: "m" is an integer ranging from zero to two; "n" and "p" are integers ranging from zero to five; and $n+p=2m+1$. Additionally, groups R_{4-9} can each be hydrogen, fluorine or methyl groups. As with the other groups, the identity of each of R_{4-9} is selected independent of the identity of the other groups. Finally, the identity of group R' in General

Chemical Structure C is either O, S, a carbonyl group or an ester group. Each of the solvent compounds characterized by General Chemical Structure C is suitable for use as an organic solvent in the cleaning processes of the invention. The types of glycol ether compounds that are encompassed by this chemical structure include, but are not limited to, aliphatic and fluorinated and partially fluorinated aliphatic mono and poly glycol diethers and ether thioethers and carbonyl and ester derivatives thereof.

The General Chemical Structure C described above can also be broken down further into various subgroups, as is shown in Table 2 below.

| TABLE 2 | | | | | | | |
|-----------|---|------------------|------------------|---|----------------------|----------------------------------|----------------------------------|
| Sub-group | R ₁₋₃ | R ₄₋₆ | R ₇₋₉ | R ₁₀₋₁₂ | R' | R'' | R ^{IV} |
| C1 | H or CH ₃ | H | H | H | O | C _j H _{2j+1} | C _k H _{2k+1} |
| C2 | H or CH ₃ | H | H | H | S, carbonyl or ester | C _j H _{2j+1} | C _k H _{2k+1} |
| C3 | H, CH ₃ , or C ₂ H ₅ and at least one is CH ₂ CH ₃ | H | H | H | O | C _j H _{2j+1} | C _k H _{2k+1} |
| C4 | H, CH ₃ , or C ₂ H ₅ and at least one is CH ₂ CH ₃ | H | H | H | S, carbonyl or ester | C _j H _{2j+1} | C _k H _{2k+1} |
| C5 | H | H | H | H or CH ₃ and at least one is CH ₃ | O | C _j H _{2j+1} | C _k H _{2k+1} |
| C6 | H | H | H | H or CH ₃ and at least one is CH ₃ | S, carbonyl or ester | C _j H _{2j+1} | C _k H _{2k+1} |
| C7 | H | H | H | H, CH ₃ or C ₂ H ₅ and at least one is CH ₂ CH ₃ | O | C _j H _{2j+1} | C _k H _{2k+1} |
| C8 | H | H | H | H, CH ₃ or C ₂ H ₅ and at least one is CH ₂ CH ₃ | S, carbonyl or ester | C _j H _{2j+1} | C _k H _{2k+1} |

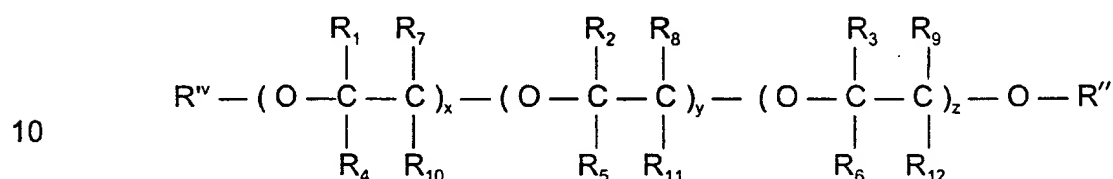
TABLE 2

| Sub-group | R ₁₋₃ | R ₄₋₆ | R ₇₋₉ | R ₁₀₋₁₂ | R' | R'' | R ^{IV} |
|-----------|---|---|---|---|-------------------------|--|--|
| C9 | H, F, CH ₃ , CH ₂ F, CHF ₂ , or CF ₃ | H or F | H or F | H or F | O | C _j H _u F _v | C _k H _t F _s |
| C10 | H, F, CH ₃ , CH ₂ F, CHF ₂ , or CF ₃ | H or F | H or F | H or F | S, carbonyl or ester | C _j H _u F _v | C _k H _t F _s |
| C11 | C _m H _n F _p and at least one is C ₂ H _n F _p | H or F | H or F | H or F | O | C _j H _u F _v | C _k H _t F _s |
| C12 | C _m H _n F _p and at least one is C ₂ H _n F _p | H or F | H or F | H or F | S, carbonyl or ester | C _j H _u F _v | C _k H _t F _s |
| C13 | H or F | H or F | H or F | H, F, CH ₃ , CH ₂ F, CHF ₂ or CF ₃ and at least one is CH ₃ , CH ₂ F, CHF ₂ or CF ₃ | O | C _j H _u F _v | C _k H _t F _s |
| C14 | H or F | H or F | H or F | H, F, CH ₃ , CH ₂ F, CHF ₂ or CF ₃ and at least one is CH ₃ , CH ₂ F, CHF ₂ or CF ₃ | S, carbonyl or ester | C _j H _u F _v | C _k H _t F _s |
| C15 | H, F, CH ₃ , CH ₂ F, CHF ₂ , or CF ₃ | H, F, CH ₃ , CH ₂ F, CHF ₂ , or CF ₃ | H, F, CH ₃ , CH ₂ F, CHF ₂ , or CF ₃ | C _m H _n F _p and at least one is C ₂ H _n F _p | O | C _j H _u F _v | C _k H _t F _s |
| C16 | H, F, CH ₃ , CH ₂ F, CHF ₂ , or CF ₃ | H, F, CH ₃ , CH ₂ F, CHF ₂ , or CF ₃ | H, F, CH ₃ , CH ₂ F, CHF ₂ , or CF ₃ | C _m H _n F _p and at least one is C ₂ H _n F _p | S, carbonyl or ester | C _j H _u F _v | C _k H _t F _s |

- 10 In each of the groups described in Table 2 above, one or more of R₁₋₁₂ are described together. For example, R₁₋₃ may be described as "H or CH₃ independently." In a given solvent compound with this description, each of R₁, R₂ and R₃ may be H or

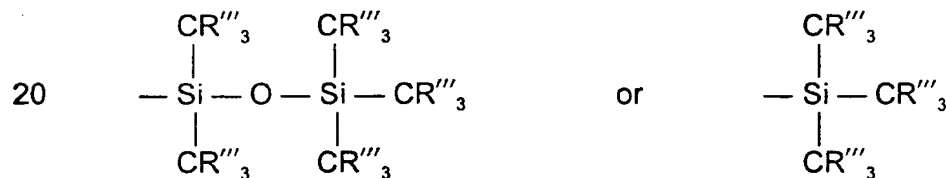
each of R_1 , R_2 and R_3 may be CH_3 . Alternatively, R_1 and R_2 may be H while R_3 is CH_3 , and so forth with the various combinations of "H" and " CH_3 ".

In another embodiment of the processes of the invention, substrates are cleaned with an organic solvent and the organic solvent is removed from the
 5 substrates using a pressurized fluid solvent. The organic solvent can have a structural formula as follows:

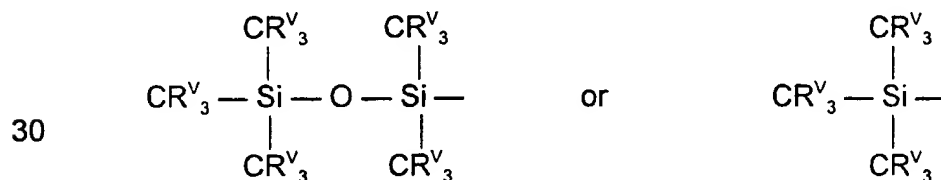


General Chemical Structure D

15 In General Chemical Structure D, subscripts "x", "y" and "z" each have a value of either zero or one, but at least one of "x", "y" and "z" has a value of one. Group R'' is either H or has one of the following structures:



where R''' is H, F or combinations of H and F and group R^V is either H or one of the
 25 following structures:

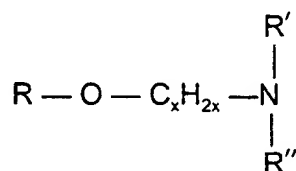


where R^V is H, F or combinations of H and F. Where R'' is H or F, R^V is not H or F.

Groups R''' and R^V are either H or F groups or combinations of H and F. Therefore, within a given R'' or R^V group, the R''' groups and R^V groups can be both hydrogens and fluorines; they are not limited to being only hydrogen or fluorine. In further defining General Chemical Structure D, groups $R_{1,3}$ can be H, F, CH_3 , CH_2F , CHF_2 or CF_3 . Each one of R_{4-12} is independently either H or F.

In another embodiment of the processes of the invention, substrates are cleaned with an organic solvent and the organic solvent is removed from the substrates using a pressurized fluid solvent. The organic solvent can have a structural formula as follows:

10

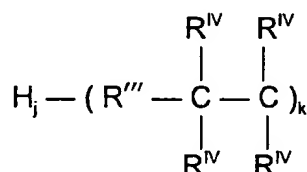


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General Chemical Structure E

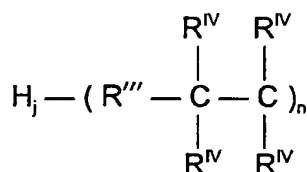
In General Chemical Structure E, R' is:

20



and R'' is:

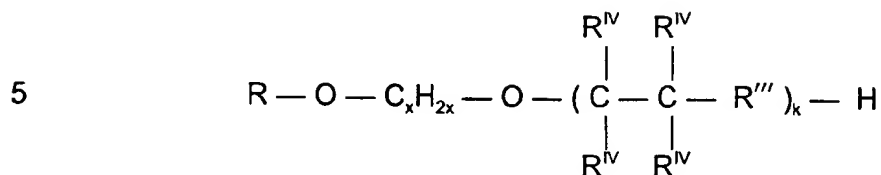
25



Each R''' is O or N independently. Where R''' is O, j is 1. Where R''' is N, j is 2. Each R^{IV} is independently H, CH_3 or CH_2CH_3 and k and n are integers between zero and two inclusive. R is C_yH_{2y+1} and y is an integer between one and $(12 - (3k + 3n + x))$ inclusive, and x is an integer between one and $(12 - (3k + y))$, inclusive.

In another embodiment of the processes of the invention, substrates are cleaned with an organic solvent and the organic solvent is removed from the

substrates using a pressurized fluid solvent. The organic solvent can have a structural formula as follows:



General Chemical Structure F

- 10 In General Chemical Structure F, R''' is O or R''' is NH. Each R^{IV} is independently H, CH₃ or CH₂CH₃ and k is an integer between zero and two inclusive. R is C_yH_{2y+1} and y is an integer between one and (12-(3k+x)) inclusive, and x is an integer between one and (12-(3k+y)), inclusive, and x+y is less than or equal to 12.

Referring now to FIG. 1, a block diagram of a cleaning system having
 15 separate vessels for cleaning and drying textiles is shown. The cleaning system 100 generally comprises a cleaning machine 102 having a cleaning vessel 110 operatively connected to, via one or more motor activated shafts (not shown), a perforated rotatable cleaning drum or wheel 112 within the cleaning vessel 110 with an inlet 114 to the cleaning vessel 110 and an outlet 116 from the cleaning vessel
 20 110 through which cleaning fluids can pass. A drying machine 104 has a drying vessel 120 capable of being pressurized. The pressurizable drying vessel 120 is operatively connected to, via one or more motor activated shafts (not shown), a perforated rotatable drying drum or wheel 122 within the drying vessel 120 with an inlet 124 to the drying vessel 120 and an outlet 126 from the drying vessel 120
 25 through which pressurized fluid solvent can pass. The cleaning vessel 110 and the drying vessel 120 can either be parts of the same machine, or they can comprise separate machines. Furthermore, both the cleaning and drying steps of this invention can be performed in the same vessel, as is described with respect to FIG. 2 below.

- 30 An organic solvent tank 130 holds any suitable organic solvent, as previously described, to be introduced to the cleaning vessel 110 through the inlet 114. A pressurized fluid solvent tank 132 holds pressurized fluid solvent to be added to the

pressurizable drying vessel 120 through the inlet 124. Filtration assembly 140 contains one or more filters that continuously remove contaminants from the organic solvent from the cleaning vessel 110 as cleaning occurs.

5 The components of the cleaning system 100 are connected with lines 150-156, which transfer organic solvents and vaporized and pressurized fluid solvents between components of the system. The term "line" as used herein is understood to refer to a piping network or similar conduit capable of conveying fluid and, for certain purposes, is capable of being pressurized. The transfer of the organic solvents and vaporized and pressurized fluid solvents through the lines 150-156 is directed by
10 valves 170-176 and pumps 190-193. While pumps 190-193 are shown in the described embodiment, any method of transferring liquid and/or vapor between components can be used, such as adding pressure to the component using a compressor to force the liquid and/or vapor from the component.

The textiles are cleaned with an organic solvent such as those previously
15 described or mixtures thereof. The textiles may also be cleaned with a combination of organic solvent and pressurized fluid solvent, and this combination may be in varying proportions from about 50% by weight to 100% by weight of organic solvent and 0% by weight to 50% by weight of pressurized fluid solvent. In the cleaning process, the textiles are first sorted as necessary to place the textiles into groups
20 suitable to be cleaned together. The textiles may then be spot treated as necessary to remove any stains that may not be removed during the cleaning process. The textiles are then placed into the cleaning drum 112 of the cleaning system 100. It is preferred that the cleaning drum 112 be perforated to allow for free interchange of solvent between the cleaning drum 112 and the cleaning vessel 110 as well as to
25 transport soil from the textiles to the filtration assembly 140.

After the textiles are placed in the cleaning drum 112, an organic solvent contained in the organic solvent tank 130 is added to the cleaning vessel 110 via line 152 by opening valve 171, closing valves 170, 172, 173 and 174, and activating pump 190 to pump organic solvent through the inlet 114 of the cleaning vessel 110.
30 The organic solvent may contain one or more co-solvents, water, detergents, or other additives to enhance the cleaning capability of the cleaning system 100.

Alternatively, one or more additives may be added directly to the cleaning vessel 110. Pressurized fluid solvent may also be added to the cleaning vessel 110 along with the organic solvent to enhance cleaning. Pressurized fluid solvent can be added to the cleaning vessel 110 via line 154 by opening valve 174, closing valves 5 170, 171, 172, 173, and 175, and activating pump 192 to pump pressurized fluid solvent through the inlet 114 of the cleaning vessel 110. Of course, if pressurized fluid solvent is included in the cleaning cycle, the cleaning vessel 110 will need to be pressurized in the same manner as the drying vessel 120, as discussed below.

When a sufficient amount of the organic solvent, or combination of organic 10 solvent and pressurized fluid solvent, is added to the cleaning vessel 110, the motor (not shown) is activated and the perforated cleaning drum 112 is agitated and/or rotated within cleaning vessel 110. During this phase, the organic solvent is continuously cycled through the filtration assembly 140 by opening valves 170 and 172, closing valves 171, 173 and 174, and activating pump 191. Filtration assembly 15 140 may include one or more fine mesh filters to remove particulate contaminants from the organic solvent passing therethrough and may alternatively or in addition include one or more absorptive or adsorptive filters to remove water, dyes and other dissolved contaminants from the organic solvent. Exemplary configurations for filter assemblies that can be used to remove contaminants from either the organic solvent 20 or the pressurized fluid solvent are described more fully in U.S. Application Serial No. 08/994,583 incorporated herein by reference. As a result, the organic solvent is pumped through outlet 116, valve 172, line 151, filter assembly 140, line 150, valve 170 and re-enters the cleaning vessel 110 via inlet 114. This cycling advantageously removes contaminants, including particulate contaminants and/or soluble 25 contaminants, from the organic solvent and reintroduces filtered organic solvent to the cleaning vessel 110 and agitating or rotating cleaning drum 112. Through this process, contaminants are removed from the textiles. Of course, in the event the cleaning vessel 110 is pressurized, this recirculation system will be maintained at the same pressure/temperature levels as those in cleaning vessel 110.

30 After sufficient time has passed so that the desired level of contaminants is removed from the textiles and organic solvent, the organic solvent is removed from

the cleaning drum 112 and cleaning vessel 110 by opening valve 173, closing valves 170, 171, 172 and 174, and activating pump 191 to pump the organic solvent through outlet 116 via line 153. The cleaning drum 112 is then rotated at a high speed, such as 150-800 rpm, to further remove organic solvent from the textiles.

- 5 The cleaning drum 112 is preferably perforated so that, when the textiles are rotated in the cleaning drum 112 at a high speed, such as 150-800 rpm, the organic solvent can drain from the cleaning drum 112. Any organic solvent removed from the textiles by rotating the cleaning drum 112 at high speed is also removed from the cleaning drum 112 in the manner described above. After the organic solvent is removed from the cleaning drum 112, it can either be discarded or recovered and decontaminated for reuse using solvent recovery systems known in the art. Furthermore, multiple cleaning cycles can be used if desired, with each cleaning cycle using the same organic solvent or different organic solvents. If multiple cleaning cycles are used, each cleaning cycle can occur in the same cleaning vessel, or a separate cleaning vessel can be used for each cleaning cycle.

- 15 After a desired amount of the organic solvent is removed from the textiles by rotating the cleaning drum 112 at high speed, the textiles are moved from the cleaning drum 112 to the drying drum 122 within the drying vessel 120 in the same manner textiles are moved between machines in conventional cleaning systems. In an alternate embodiment, a single drum can be used in both the cleaning cycle and the drying cycle, so that, rather than transferring the textiles between the cleaning drum 112 and the drying drum 122, a single drum containing the textiles is transferred between the cleaning vessel 110 and the drying vessel 120. If the cleaning vessel 110 is pressurized during the cleaning cycle, it must be depressurized before the textiles are removed. Once the textiles have been placed in the drying drum 122, pressurized fluid solvent, such as that contained in the carbon dioxide tank 132, is added to the drying vessel 120 via lines 154 and 155 by opening valve 175, closing valves 174 and 176, and activating pump 192 to pump pressurized fluid solvent through the inlet 124 of the drying vessel 120 via lines 154 and 155. When pressurized fluid solvent is added to the drying vessel 120, the organic solvent remaining on the textiles dissolves in the pressurized fluid solvent.

After a sufficient amount of pressurized fluid solvent is added so that the desired level of organic solvent has been dissolved, the pressurized fluid solvent and organic solvent combination is removed from the drying vessel 120, and therefore also from the drying drum 122, by opening valve 176, closing valve 175 and
5 activating pump 193 to pump the pressurized fluid solvent and organic solvent combination through outlet 126 via line 156. If desired, this process may be repeated to remove additional organic solvent. The drying drum 122 is then rotated at a high speed, such as 150-800 rpm, to further remove the pressurized fluid solvent and organic solvent combination from the textiles. The drying drum 122 is
10 preferably perforated so that, when the textiles are rotated in the drying drum 122 at a high speed, the pressurized fluid solvent and organic solvent combination can drain from the drying drum 122. Any pressurized fluid solvent and organic solvent combination removed from the textiles by spinning the drying drum 122 at high speed is also pumped from the drying vessel 120 in the manner described above.
15 After the pressurized fluid solvent and organic solvent combination is removed from the drying vessel 120, it can either be discarded or separated and recovered for reuse with solvent recovery systems known in the art. Note that, while preferred, it is not necessary to include a high speed spin cycle to remove pressurized fluid solvent from the textiles.

20 After a desired amount of the pressurized fluid solvent is removed from the textiles by rotating the drying drum 122, the drying vessel 120 is depressurized over a period of about 5-15 minutes. The depressurization of the drying vessel 120 vaporizes any remaining pressurized fluid solvent, leaving dry, solvent-free textiles in the drying drum 122. The pressurized fluid solvent that has been vaporized is then
25 removed from the drying vessel 120 by opening valve 176, closing valve 175, and activating pump 193. As a result, the vaporized pressurized fluid solvent is pumped through the outlet 126, line 156 and valve 176, where it can then either be vented to the atmosphere or recovered and recompressed for reuse.

While the cleaning system 100 has been described as a complete system, an
30 existing conventional dry cleaning system may be converted for use in accordance with the present invention. To convert a conventional dry cleaning system, the

organic solvent described above is used to clean textiles in the conventional system. A separate pressurized vessel is added to the conventional system for drying the textiles with pressurized fluid solvent. Thus, the conventional system is converted for use with a pressurized fluid solvent. For example, the system in FIG. 1 could

5 represent such a converted system, wherein the components of the cleaning machine 102 are conventional, and the pressurized fluid solvent tank 132 is not in communication with the cleaning vessel 100. In such a situation, the drying machine 104 is the add-on part of the conventional cleaning machine.

Furthermore, while the system shown in FIG. 1 comprises a single cleaning

10 vessel, multiple cleaning vessels could be used, so that the textiles are subjected to multiple cleaning steps, with each cleaning step carried out in a different cleaning vessel using the same or different organic solvents in each step. The description of the single cleaning vessel is merely for purposes of description and should not be construed as limiting the scope of the invention.

15 Referring now to FIG. 2, a block diagram of an alternate embodiment of the present invention, a cleaning system having a single chamber for cleaning and drying the textiles, is shown. The cleaning system 200 generally comprises a cleaning machine having a pressurizable vessel 210. The vessel 210 is operatively connected to, via one or more motor activated shafts (not shown), a perforated

20 rotatable drum or wheel 212 within the vessel 210 with an inlet 214 to the vessel 210 and an outlet 216 from the vessel 210 through which dry cleaning fluids can pass.

An organic solvent tank 220 holds any suitable organic solvent, such as those described above, to be introduced to the vessel 210 through the inlet 214. A pressurized fluid solvent tank 222 holds pressurized fluid solvent to be added to the

25 vessel 210 through the inlet 214. Filtration assembly 224 contains one or more filters that continuously remove contaminants from the organic solvent from the vessel 210 and drum 212 as cleaning occurs.

The components of the cleaning system 200 are connected with lines 230-234 that transfer organic solvents and vaporized and pressurized fluid solvent between

30 components of the system. The term "line" as used herein is understood to refer to a piping network or similar conduit capable of conveying fluid and, for certain

purposes, is capable of being pressurized. The transfer of the organic solvents and vaporized and pressurized fluid solvent through the lines 230-234 is directed by valves 250-254 and pumps 240-242. While pumps 240-242 are shown in the described embodiment, any method of transferring liquid and/or vapor between
5 components can be used, such as adding pressure to the component using a compressor to force the liquid and/or vapor from the component.

The textiles are cleaned with an organic solvent such as those previously described. The textiles may also be cleaned with a combination of organic solvent and pressurized fluid solvent, and this combination may be in varying proportions of
10 50-100% by weight organic solvent and 0-50% by weight pressurized fluid solvent. In the cleaning process, the textiles are first sorted as necessary to place the textiles into groups suitable to be cleaned together. The textiles may then be spot treated as necessary to remove any stains that may not be removed during the cleaning process. The textiles are then placed into the drum 212 within the vessel 210 of the
15 cleaning system 200. It is preferred that the drum 212 be perforated to allow for free interchange of solvent between the drum 212 and the vessel 210 as well as to transport soil from the textiles to the filtration assembly 224.

After the textiles are placed in the drum 212, an organic solvent contained in the organic solvent tank 220 is added to the vessel 210 via line 231 by opening valve
20 251, closing valves 250, 252, 253 and 254, and activating pump 242 to pump organic solvent through the inlet 214 of the vessel 210. The organic solvent may contain one or more co-solvents, detergents, water, or other additives to enhance the cleaning capability of the cleaning system 200. Alternatively, one or more additives may be added directly to the vessel. Pressurized fluid solvent may also be
25 added to the vessel 210 along with the organic solvent to enhance cleaning. The pressurized fluid solvent is added to the vessel 210 via line 230 by opening valve 250, closing valves 251, 252, 253 and 254, and activating pump 240 to pump the pressurized fluid solvent through the inlet 214 of the vessel 210.

When the desired amount of the organic solvent, or combination of organic
30 solvent and pressurized fluid solvent as described above, is added to the vessel 210, the motor (not shown) is activated and the drum 212 is agitated and/or rotated.

During this phase, the organic solvent, as well as pressurized fluid solvent if used in combination, is continuously cycled through the filtration assembly 224 by opening valves 252 and 253, closing valves 250, 251 and 254, and activating pump 241.

Filtration assembly 224 may include one or more fine mesh filters to remove

- 5 particulate contaminants from the organic solvent and pressurized fluid solvent passing therethrough and may alternatively or in addition include one or more absorptive or adsorptive filters to remove water, dyes, and other dissolved contaminants from the organic solvent. Exemplary configurations for filter assemblies that can be used to remove contaminants from either the organic solvent
10 or the pressurized fluid solvent are described more fully in U.S. Application Serial No. 08/994,583 incorporated herein by reference. As a result, the organic solvent is pumped through outlet 216, valve 253, line 233, filter assembly 224, line 232, valve 252 and reenters the vessel 210 via inlet 214. This cycling advantageously removes contaminants, including particulate contaminants and/or soluble contaminants, from
15 the organic solvent and pressurized fluid solvent and reintroduces filtered solvent to the vessel 210. Through this process, contaminants are removed from the textiles.

- After sufficient time has passed so that the desired level of contaminants is removed from the textiles and solvents, the organic solvent is removed from the vessel 210 and drum 212 by opening valve 254, closing valves 250, 251, 252 and
20 253, and activating pump 241 to pump the organic solvent through outlet 216 and line 234. If pressurized fluid solvent is used in combination with organic solvent, it may be necessary to first separate the pressurized fluid solvent from the organic solvent. The organic solvent can then either be discarded or, preferably, contaminants may be removed from the organic solvent and the organic solvent
25 recovered for further use. Contaminants may be removed from the organic solvent with solvent recovery systems known in the art. The drum 212 is then rotated at a high speed, such as 150-800 rpm, to further remove organic solvent from the textiles. The drum 212 is preferably perforated so that, when the textiles are rotated in the drum 212 at a high speed, the organic solvent can drain from the cleaning
30 drum 212. Any organic solvent removed from the textiles by rotating the drum 212 at high speed can also either be discarded or recovered for further use.

After a desired amount of organic solvent is removed from the textiles by rotating the drum 212, pressurized fluid solvent contained in the pressurized fluid tank 222 is added to the vessel 210 by opening valve 250, closing valves 251, 252, 253 and 254, and activating pump 240 to pump pressurized fluid solvent through the inlet 214 of the pressurizable vessel 210 via line 230. When pressurized fluid solvent is added to the vessel 210, organic solvent remaining on the textiles dissolves in the pressurized fluid solvent.

After a sufficient amount of pressurized fluid solvent is added so that the desired level of organic solvent has been dissolved, the pressurized fluid solvent and organic solvent combination is removed from the vessel 210 by opening valve 254, closing valves 250, 251, 252 and 253, and activating pump 241 to pump the pressurized fluid solvent and organic solvent combination through outlet 216 and line 234. Note that pump 241 may actually require two pumps, one for pumping the low pressure organic solvent in the cleaning cycle and one for pumping the pressurized fluid solvent in the drying cycle.

The pressurized fluid solvent and organic solvent combination can then either be discarded or the combination may be separated and the organic solvent and pressurized fluid solvent separately recovered for further use. The drum 212 is then rotated at a high speed, such as 150-800 rpm, to further remove pressurized fluid solvent and organic solvent combination from the textiles. Any pressurized fluid solvent and organic solvent combination removed from the textiles by spinning the drum 212 at high speed can also either be discarded or retained for further use. Note that, while preferred, it is not necessary to include a high speed spin cycle to remove pressurized fluid solvent from the textiles.

After a desired amount of the pressurized fluid solvent is removed from the textiles by rotating the drum 212, the vessel 210 is depressurized over a period of about 5-15 minutes. The depressurization of the vessel 210 vaporizes the pressurized fluid solvent, leaving dry, solvent-free textiles in the drum 212. The pressurized fluid solvent that has been vaporized is then removed from the vessel 210 by opening valve 254, closing valves 250, 251, 252 and 253, and activating pump 241 to pump the vaporized pressurized fluid solvent through outlet 216 and

line 234. Note that while a single pump is shown as pump 241, separate pumps may be necessary to pump organic solvent, pressurized fluid solvent and pressurized fluid solvent vapors, at pump 241. The remaining vaporized pressurized fluid solvent can then either be vented into the atmosphere or compressed back into pressurized fluid solvent for further use.

As discussed above, dipropylene glycol n-butyl ether, tripropylene glycol n-butyl ether and tripropylene glycol methyl ether are the preferred organic solvents for use in the present invention, as shown in the test results below. Table 3 shows results of detergency testing for each of a number of solvents that may be suitable for use in the present invention. Table 4 shows results of testing of drying and extraction of those solvents using densified carbon dioxide.

Detergency tests were performed using a number of different solvents without detergents, co-solvents, or other additives. The solvents selected for testing include organic solvents and liquid carbon dioxide. Two aspects of detergency were investigated - soil removal and soil redeposition. The former refers to the ability of a solvent to remove soil from a substrate while the latter refers to the ability of a solvent to prevent soil from being redeposited on a substrate during the cleaning process. Wascherei Forschungs Institute, Krefeld Germany ("WFK") standard soiled swatches that have been stained with a range of insoluble materials and WFK white cotton swatches, both obtained from TESTFABRICS, Inc., were used to evaluate soil removal and soil redeposition, respectively.

Soil removal and redeposition for each solvent was quantified using the Delta Whiteness Index. This method entails measuring the Whiteness Index of each swatch before and after processing. The Delta Whiteness Index is calculated by subtracting the Whiteness Index of the swatch before processing from the Whiteness Index of the swatch after processing. The Whiteness Index is a function of the light reflectance of the swatch and in this application is an indication of the amount of soil on the swatch. More soil results in a lower light reflectance and Whiteness Index for the swatch. The Whiteness indices were measured using a reflectometer manufactured by Hunter Laboratories.

Organic solvent testing was carried out in a Launder-Ometer while the densified carbon dioxide testing was carried out in a Parr Bomb. After measuring their Whiteness Indices, two WFK standard soil swatches and two WFK white cotton swatches were placed in a Launder-Ometer cup with 25 stainless steel ball bearings and 150 mL of the solvent of interest. The cup was then sealed, placed in the Launder-Ometer and agitated for a specified length of time. Afterwards, the swatches were removed and placed in a Parr Bomb equipped with a mesh basket. Approximately 1.5 liters of liquid carbon dioxide between 5°C and 25°C and 570 psig and 830 psig was transferred to the Parr Bomb. After several minutes the Parr Bomb was vented and the dry swatches removed and allowed to reach room temperature. Testing of densified carbon dioxide was carried out by placing the swatches in a Parr Bomb, transferring liquid carbon dioxide at 20°C and 830 psig to the Parr Bomb. The swatches were fastened to a wire frame attached to a rotatable shaft to enable the swatches to be agitated while immersed in the liquid carbon dioxide. The Whiteness Index of the processed swatches was determined using the reflectometer. The two Delta Whiteness Indices obtained for each pair of swatches were averaged. The results are presented in Table 3.

Because the Delta Whiteness Index is calculated by subtracting the Whiteness Index of a swatch before processing from the Whiteness Index value after processing, a positive Delta Whiteness Index indicates that there was an increase in Whiteness Index as a result of processing. In practical terms, this means that soil was removed during processing. In fact, the higher the Delta Whiteness Value, the more soil was removed from the swatch during processing. Each of the organic solvents tested exhibited significant soil removal. Densified carbon dioxide alone, on the other hand, exhibited no soil removal. The WFK white cotton swatches exhibited a decrease in Delta Whiteness Indices indicating that the soil was deposited on the swatches during the cleaning process. Therefore, a "less negative" Delta Whiteness Index suggests that less soil was redeposited. It should be noted that the seemingly excellent result obtained for densified carbon dioxide is an anomaly and resulted from the fact that essentially no soil removal took place and therefore essentially no

soil was present in the solvent which could be deposited on the swatch. The organic solvents on the other hand, exhibited good soil redeposition results.

TABLE 3

| Solvent | Cleaning Time (minutes) | Delta Whiteness Values | |
|---|----------------------------|---------------------------|--------------------------------|
| | | Insoluble Soil Removal | Insoluble Soil Redeposition |
| Densified Carbon Dioxide (at 20°C and 830 psig) | 20 | 0.00 | -0.54 |
| Ethylene Glycol Ethyl Ether | 12 | 13.87 | -5.10 |
| Ethylene Glycol Ethyl Ether Acetate | 12 | 16.10 | -11.40 |
| Diethylene Glycol Butyl Ether | 12 | 12.80 | -5.11 |
| Propylene Glycol t-butyl Ether | 12 | 14.35 | -13.50 |
| Dipropylene Glycol Methyl Ether | 20 | 11.84 | -5.64 |
| Tripropylene Glycol Methyl Ether | 12 | 13.48 | -5.60 |
| Dipropylene Glycol n-Butyl Ether | 12 | 13.97 | -6.22 |
| Dipropylene Glycol n-Propyl Ether | 12 | 13.15 | -7.50 |
| Tripropylene Glycol n-Butyl Ether | 12 | 13.24 | -4.35 |

To evaluate the ability of densified carbon dioxide to extract organic solvent from a substrate, WFK white cotton swatches were used. One swatch was weighed dry and then immersed in an organic solvent sample. Excess solvent was removed from the swatch using a ringer manufactured by Atlas Electric Devices Company. The damp swatch was re-weighed to determine the amount of solvent retained in the fabric. After placing the damp swatch in a Parr Bomb densified carbon dioxide was transferred to the Parr Bomb. The temperature and pressure of the densified carbon dioxide for all of the trials ranged from 5°C to 20°C and from 570 psig - 830 psig. After five minutes the Parr Bomb was vented and the swatch removed. The swatch was next subjected to Soxhlet extraction using methylene chloride for a minimum of two hours. This apparatus enables the swatch to be continuously extracted to remove the organic solvent from the swatch. After determining the concentration of the organic solvent in the extract using gas chromatography, the amount of organic

solvent remaining on the swatch after exposure to densified carbon dioxide was calculated by multiplying the concentration of the organic solvent in the extract by the volume of the extract. A different swatch was used for each of the tests. The results of these tests are included in Table 4. As the results indicate, the extraction process

5 using densified carbon dioxide is extremely effective.

| TABLE 4 | | | | |
|--------------------------------------|--|------------------|---|---|
| Solvent | Weight of Solvent on Test Swatch (grams) | | Weight of Densified Carbon Dioxide Used (kilograms) | Percentage by Weight of Solvent Removed from Swatch |
| | Before Extraction | After Extraction | | |
| 10 Ethylene Glycol Ethyl Ether | 1.8718 | 0.0069 | 1.35 | 99.63 |
| Ethylene Glycol Ethyl Ether Acetate | 1.9017 | 0.0002 | 1.48 | 99.99 |
| 15 Diethylene Glycol Butyl Ether | 1.9548 | 0.0033 | 1.72 | 99.83 |
| Propylene Glycol t-butyl Ether | 2.0927 | 0.0010 | 1.24 | 99.95 |
| Dipropylene Glycol Methyl Ether | 2.1209 | 0.0005 | 1.31 | 99.98 |
| 20 Tripropylene Glycol Methyl Ether | 1.9910 | 0.0022 | 1.71 | 99.89 |
| Dipropylene Glycol n-Butyl Ether | 1.8005 | 0.0023 | 1.77 | 99.87 |
| 25 Dipropylene Glycol n-Butyl Ether | 1.7096 | 0.0034 | 1.59 | 99.80 |
| Dipropylene Glycol n-Butyl Ether | 1.7651 | 0.0018 | 3.36 | 99.90 |
| Dipropylene Glycol n-Propyl Ether | 1.7958 | 0.0012 | 1.48 | 99.94 |
| 30 Tripropylene Glycol n-Butyl Ether | 1.8670 | 0.0034 | 1.30 | 99.82 |

It is to be understood that a wide range of changes and modifications to the embodiments described above will be apparent to those skilled in the art and are contemplated. It is, therefore, intended that the foregoing detailed description be

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regarded as illustrative rather than limiting, and that it be understood that it is the following claims, including all equivalents, that are intended to define the spirit and scope of the invention.

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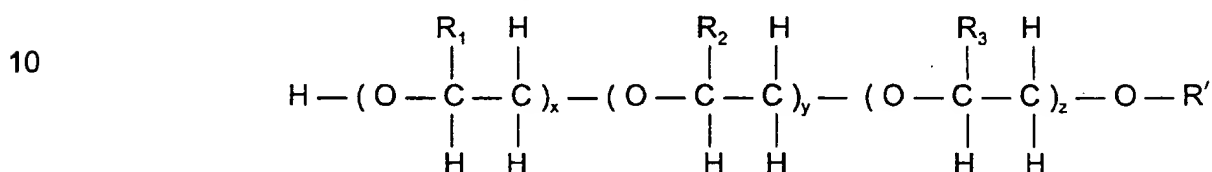
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CLAIMS

What is claimed is:

1. A process for cleaning substrates comprising:
 5 cleaning the substrates with an organic solvent; and
 removing the organic solvent from the substrates using a pressurized fluid
 solvent;

wherein the organic solvent is of the structural formula:



wherein x, y, and z each is zero or one;

15 at least one of x, y, and z is one;

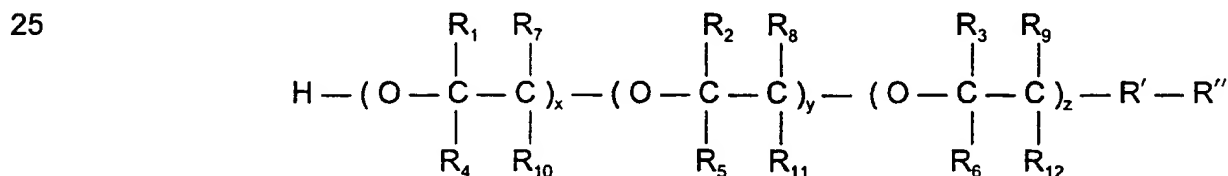
R' is C_jH_{2j+1} wherein j is an integer between one and (13-3(x+y+z)), inclusive;

and

R_{1,3} are independently H or CH₃.

- 20 2. A process for cleaning substrates comprising:
 cleaning the substrates with an organic solvent; and
 removing the organic solvent from the substrates using a pressurized fluid
 solvent;

wherein the organic solvent is of the structural formula:



30 wherein x, y, and z each is zero or one;

at least one of x, y, and z is one;

R'' is benzyl, phenyl, partially or fully fluorinated benzyl or phenyl, C_jH_{2j+1}, or
 C_jH_aF_b wherein j is an integer between one and (13-3(x+y+z)), inclusive, a and b
 each is independently an integer between zero and 2j+1, inclusive, and a+b=2j+1;

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R_{1-12} are independently $C_mH_nF_p$ or $C_dH_eF_g$ where m is an integer between zero and two, inclusive, n and p are integers between zero and five, inclusive and $n+p=2m+1$, d is an integer between zero and two, inclusive, e and g are integers between zero and five, inclusive, and $e+g=2d+1$; and

5 R' is O, S, carbonyl or ester.

3. The process of claim 2 wherein:

R' is O;

R'' is C_jH_{2j+1} ;

10 R_{1-3} are independently H or CH_3 ; and

R_{4-12} each is H.

4. The process of claim 2 wherein:

R' is S, carbonyl or ester;

15 R'' is C_jH_{2j+1} ;

R_{1-3} are independently H or CH_3 ; and

R_{4-12} each is H.

5. The process of claim 2 wherein:

20 R' is O;

R'' is C_jH_{2j+1} ;

R_{1-3} are independently H, CH_3 , or C_2H_5 ; and

at least one of R_{1-3} is CH_2CH_3 ; and

25 R_{4-12} are each H.

6. The process of claim 2 wherein:

R' is S, carbonyl or ester;

30 R'' is C_jH_{2j+1} ;

R_{1-3} are independently H, CH_3 , or C_2H_5 ; and

at least one of R_{1-3} is CH_2CH_3 ; and

R_{4-12} are each H.

7. The process of claim 2 wherein:
R' is O;
R'' is C_jH_{2j+1};
R₁₋₉ are each H;
R₁₀₋₁₂ are independently H or CH₃; and
at least one of R₁₀₋₁₂ is CH₃.
8. The process of claim 2 wherein:
R' is S, carbonyl or ester;
R'' is C_jH_{2j+1};
R₁₋₉ are each H;
R₁₀₋₁₂ are independently H or CH₃; and
at least one of R₁₀₋₁₂ is CH₃.
9. The process of claim 2 wherein:
R' is O;
R'' is C_jH_{2j+1};
R₁₋₉ are each H;
R₁₀₋₁₂ are independently H, CH₃, or C₂H₅; and
at least one of R₁₀₋₁₂ is CH₂CH₃.
10. The process of claim 2 wherein:
R' is S, carbonyl or ester;
R'' is C_jH_{2j+1};
R₁₋₉ are each H;
R₁₀₋₁₂ are independently H, CH₃, or C₂H₅; and
at least one of R₁₀₋₁₂ is CH₂CH₃.

11. The process of claim 2 wherein:
R' is O;
R'' is C_jH_aF_b;
R₁₋₃ are independently H, F, CH₃, CH₂F, CHF₂, or CF₃;
And at least one is CH₃, CH₂F, CHF₂, or CF₃; and
R₄₋₁₂ are independently H or F.
12. The process of claim 2 wherein:
R' is S, carbonyl, or ester;
R'' is C_jH_aF_b;
R₁₋₃ are independently H, F, CH₃, CH₂F, CHF₂, or CF₃;
And at least one is CH₃, CH₂F, CHF₂, or CF₃; and
R₄₋₁₂ are independently H or F.
13. The process of claim 2 wherein:
R₁₋₃ are independently C_mH_nF_p;
at least one of R₁₋₃ is C₂H_nF_p;
R₄₋₁₂ are independently H or F;
R' is O; and
R'' is C_jH_aF_b.
14. The process of claim 2 wherein:
R₁₋₃ are independently C_mH_nF_p;
at least one of R₁₋₃ is C₂H_nF_p;
R₄₋₁₂ are independently H or F;
R' is S, carbonyl or ester; and
R'' is C_jH_aF_b.

- 5 15. The process of claim 2 wherein:
 R_{1-9} are independently H or F;
 R_{10-12} are independently H, F, CH_3 , CH_2F , CHF_2 or CF_3 ;
 at least one of R_{10-12} is CH_3 , CH_2F , CHF_2 or CF_3 ;
 R' is O; and
 R'' is $\text{C}_j\text{H}_a\text{F}_b$.
- 10 16. The process of claim 2 wherein:
 R_{1-9} are independently H or F;
 R_{10-12} are independently H, F, CH_3 , CH_2F , CHF_2 or CF_3 ;
 at least one of R_{10-12} is CH_3 , CH_2F , CHF_2 or CF_3 ;
 R' is S, carbonyl or ester; and
 R'' is $\text{C}_j\text{H}_a\text{F}_b$.
- 15 17. The process of claim 2 wherein:
 R' is O;
 R'' is $\text{C}_j\text{H}_a\text{F}_b$;
 R_{1-3} are independently $\text{C}_m\text{H}_n\text{F}_p$;
 R_{4-9} are independently H or F; and
20 R_{10-12} are independently $\text{C}_d\text{H}_e\text{F}_g$.
- 25 18. The process of claim 2 wherein:
 R' is S, carbonyl or ester;
 R'' is $\text{C}_j\text{H}_a\text{F}_b$;
 R_{1-3} are independently $\text{C}_m\text{H}_n\text{F}_p$;
 R_{4-9} are independently H or F; and
 R_{10-12} are independently $\text{C}_d\text{H}_e\text{F}_g$.

19. The process of claim 2 wherein:
R' is O;
R'' is benzyl or phenyl;
R₁₋₃ are independently H, CH₃, or C₂H₅;
at least one of R₁₋₃ is CH₂CH₃; and
R₄₋₁₂ are each H.

20. The process of claim 2 wherein:
R' is S, carbonyl or ester;
R'' is benzyl or phenyl;
R₁₋₃ are independently H, CH₃, or C₂H₅;
at least one of R₁₋₃ is CH₂CH₃; and
R₄₋₁₂ are each H.

21. The process of claim 2 wherein:
R' is O;
R'' is benzyl or phenyl;
R₁₋₉ are each H;
R₁₀₋₁₂ are independently H or CH₃; and
at least one of R₁₀₋₁₂ is CH₃.

22. The process of claim 2 wherein:
R' is S, carbonyl or ester;
R'' is benzyl or phenyl;
R₁₋₉ are each H;
R₁₀₋₁₂ are independently H or CH₃; and
at least one of R₁₀₋₁₂ is CH₃.

23. The process of claim 2 wherein:

R' is O;

R'' is benzyl or phenyl;

R₁₋₉ are each H;

R₁₀₋₁₂ are independently H, CH₃, or C₂H₅; and

at least one of R₁₀₋₁₂ is CH₂CH₃.

24. The process of claim 2 wherein:

R' is S, carbonyl or ester;

R'' is benzyl or phenyl;

R₁₋₉ are each H;

R₁₀₋₁₂ are independently H, CH₃, or C₂H₅; and

at least one of R₁₀₋₁₂ is CH₂CH₃.

25. The process of claim 2 wherein:

R'' is benzyl, phenyl, or partially or fully fluorinated benzyl or phenyl;

R₁₋₃ are independently C_mH_nF_p;

at least one of R₁₋₃ is C₂H_nF_p;

R₄₋₁₂ are independently H or F; and

R' is O.

26. The process of claim 2 wherein:

R'' is benzyl, phenyl, or partially or fully fluorinated benzyl or phenyl;

R₁₋₃ are independently C_mH_nF_p;

at least one of R₁₋₃ is C₂H_nF_p;

R₄₋₁₂ are independently H or F; and

R' is S, carbonyl or ester.

27. The process of claim 2 wherein:

R'' is benzyl, phenyl, or partially or fully fluorinated benzyl or phenyl;

R₁₋₉ are independently H or F;

R₁₀₋₁₂ are independently H, F, CH₃, CH₂F, CHF₂ or CF₃;

at least one of R₁₀₋₁₂ is CH₃, CH₂F, CHF₂ or CF₃; and

R' is O.

28. The process of claim 2 wherein:

R'' is benzyl, phenyl, or partially or fully fluorinated benzyl or phenyl;

R₁₋₉ are independently H or F;

R₁₀₋₁₂ are independently H, F, CH₃, CH₂F, CHF₂ or CF₃;

at least one of R₁₀₋₁₂ is CH₃, CH₂F, CHF₂ or CF₃; and

R' is S, carbonyl or ester.

29. The process of claim 2 wherein:

R'' is benzyl, phenyl, or partially or fully fluorinated benzyl or phenyl;

R₁₋₉ are independently H or F;

R₁₀₋₁₂ are independently C_mH_nF_p;

at least one of R₁₀₋₁₂ is C₂H_nF_p; and

R' is O.

30. The process of claim 2 wherein:

R'' is benzyl, phenyl, or partially or fully fluorinated benzyl or phenyl;

R₁₋₉ are independently H or F;

R₁₀₋₁₂ are independently C_mH_nF_p;

at least one of R₁₀₋₁₂ is C₂H_nF_p; and

R' is S, carbonyl or ester.

31. The process of claim 2 wherein:

R' is O;

R'' is benzyl, phenyl, or partially or fully fluorinated benzyl or phenyl;

R₁₋₃ are independently C_mH_nF_p;

R₄₋₉ are independently H or F; and

R₁₀₋₁₂ are independently C_dH_eF_g.

32. The process of claim 2 wherein:

R' is S, carbonyl or ester;

R'' is benzyl, phenyl, or partially or fully fluorinated benzyl or phenyl;

R₁₋₃ are independently C_mH_nF_p;

R₄₋₉ are independently H or F; and

R₁₀₋₁₂ are independently C_dH_eF_g.

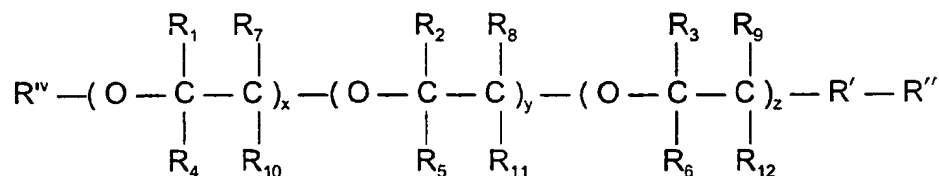
33. A process for cleaning substrates comprising:

cleaning the substrates with an organic solvent; and

removing the organic solvent from the substrates using a pressurized fluid

solvent;

wherein the organic solvent is of the structural formula:



wherein x, y, and z each is zero or one;

at least one of x, y, and z is one;

R' is C_jH_uF_v and R'' is C_kH_eF_g wherein j and k are each an integer between one and (13-3(x+y+z)), inclusive, and j+k is an integer between two and (13-3(x+y+z)), inclusive, u and v are each an integer between zero and 2j+1, inclusive,

and $u+v=2j+1$, and r and s are each an integer between zero and $2k+1$, inclusive, and $r+s=2k+1$;

R_{1-3} and R_{10-12} are independently $C_mH_nF_p$, where m is an integer between zero and two, inclusive, n and p are integers between zero and five, inclusive and $n+p=2m+1$;

R_{4-9} are independently H, F or CH_3 ; and

R' is O, S, carbonyl or ester.

34. The process of claim 33 wherein:

R' is O;

R'' is C_jH_{2j+1} ;

R^{IV} is C_kH_{2k+1} ;

R_{1-3} are independently H or CH_3 ; and

R_{4-12} are each H.

35. The process of claim 33 wherein:

R' is S, carbonyl or ester;

R'' is C_jH_{2j+1} ;

R^{IV} is C_kH_{2k+1} ;

R_{1-3} are independently H or CH_3 ; and

R_{4-12} are each H.

36. The process of claim 33 wherein:

R' is O;

R'' is C_jH_{2j+1} ;

R^{IV} is C_kH_{2k+1} ;

R_{1-3} are independently H, CH_3 , or C_2H_5 ;

at least one of R_{1-3} is CH_2CH_3 ; and

R_{4-12} are each H.

37. The process of claim 33 wherein:
R' is S, carbonyl or ester;
R'' is C_jH_{2j+1} ;
R^{IV} is C_kH_{2k+1} ;
R₁₋₃ are independently H, CH₃, or C₂H₅;
at least one of R₁₋₃ is CH₂CH₃; and
R₄₋₁₂ are each H.
38. The process of claim 33 wherein:
R' is O;
R'' is C_jH_{2j+1} ;
R^{IV} is C_kH_{2k+1} ;
R₁₋₉ are each H;
R₁₀₋₁₂ are independently H or CH₃; and
at least one of R₁₀₋₁₂ is CH₃.
39. The process of claim 33 wherein:
R' is S, carbonyl or ester;
R'' is C_jH_{2j+1} ;
R^{IV} is C_kH_{2k+1} ;
R₁₋₉ are each H;
R₁₀₋₁₂ are independently H or CH₃; and
at least one of R₁₀₋₁₂ is CH₃.
40. The process of claim 33 wherein:
R' is O;
R'' is C_jH_{2j+1} ;
R^{IV} is C_kH_{2k+1} ;
R₁₋₉ are each H;
R₁₀₋₁₂ are independently H, CH₃, or C₂H₅; and
at least one of R₁₀₋₁₂ is CH₂CH₃.

41. The process of claim 33 wherein:
R' is S, carbonyl or ester;
R'' is C_jH_{2j+1};
R^{IV} is C_kH_{2k+1};
R₁₋₉ are each H;
R₁₀₋₁₂ are independently H, CH₃, or C₂H₅; and
at least one of R₁₀₋₁₂ is CH₂CH₃.
42. The process of claim 33 wherein:
R₁₋₃ are independently H, F, CH₃, CH₂F, CHF₂, or CF₃;
R₄₋₁₂ are independently H or F; and
R' is O.
43. The process of claim 33 wherein:
R₁₋₃ are independently H, F, CH₃, CH₂F, CHF₂, or CF₃;
R₄₋₁₂ are independently H or F; and
R' is S, carbonyl or ester.
44. The process of claim 33 wherein:
at least one of R₁₋₃ is C₂H_nF_p;
R₄₋₁₂ are each independently H or F; and
R' is O.
45. The process of claim 33 wherein:
at least one of R₁₋₃ is C₂H_nF_p;
R₄₋₁₂ are each independently H or F; and
R' is S, carbonyl or ester.

46. The process of claim 33 wherein:

R_{1-9} are independently H or F;

R_{10-12} are independently H, F, CH_3 , CH_2F , CHF_2 or CF_3 ;

at least one of R_{10-12} is CH_3 , CH_2F , CHF_2 or CF_3 ; and

R' is O.

47. The process of claim 33 wherein:

R_{1-9} are independently H or F;

R_{10-12} are independently H, F, CH_3 , CH_2F , CHF_2 or CF_3 ;

at least one of R_{10-12} is CH_3 , CH_2F , CHF_2 or CF_3 ; and

R' is S, carbonyl or ester.

48. The process of claim 33 wherein:

R_{1-9} are independently H, F, CH_3 , CH_2F , CHF_2 or CF_3 ;

at least one of R_{10-12} is $C_2H_nF_p$; and

R' is O.

49. The process of claim 33 wherein:

R_{1-9} are independently H, F, CH_3 , CH_2F , CHF_2 or CF_3 ;

at least one of R_{10-12} is $C_2H_nF_p$; and

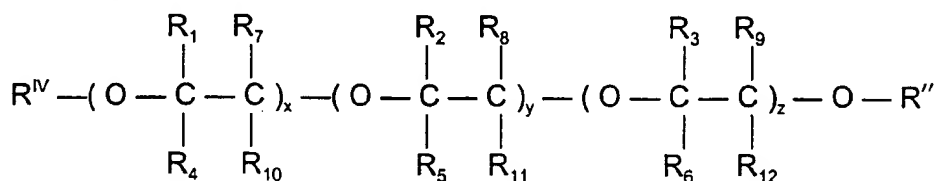
R' is S, carbonyl or ester.

50. A process for cleaning substrates comprising:

cleaning the substrates with an organic solvent; and

removing the organic solvent from the substrates using a pressurized fluid solvent;

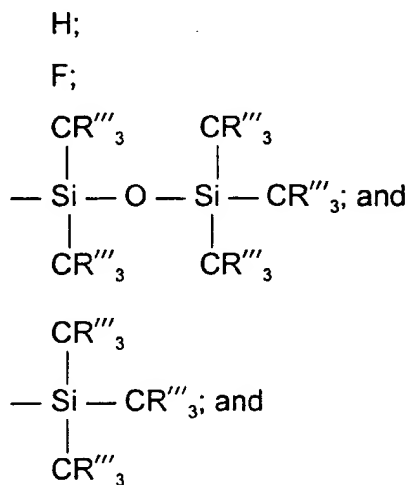
wherein the organic solvent is of the structural formula:



wherein x, y, and z are each zero or one;

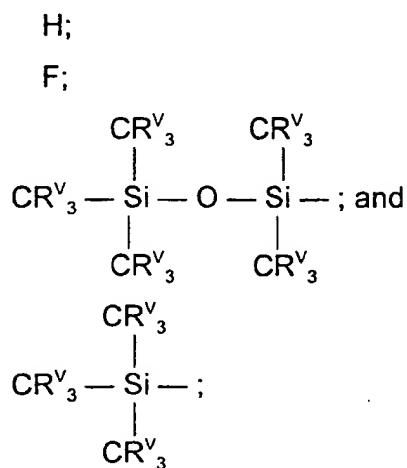
at least one of x, y, and z is one;

R'' is selected from the group including:



wherein R''' is H, F or combinations of H and F;

R^{IV} is selected from the group including:



wherein R^V is H, F or combinations of H and F; and

when R'' is H or F, R^{IV} is not H or F.

R₁₋₃ are independently H, F, CH₃, CH₂F, CHF₂ or CF₃; and

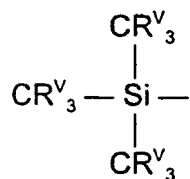
R₄₋₁₂ are independently H or F.

51. The process of claim 50 wherein:

R^{IV} is:

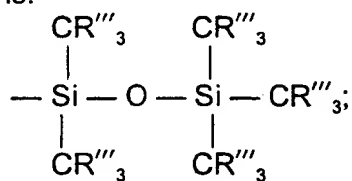
H

or



wherein R^V is H, F or combinations of H and F; and

R'' is:



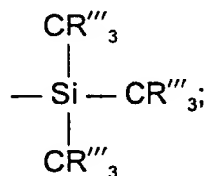
wherein R''' is H, F or combinations of H and F.

52. The process of claim 50 wherein:

R'' is:

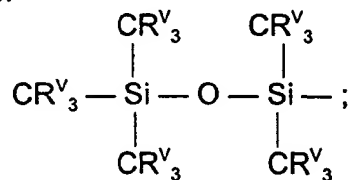
H

or



wherein R''' is H, F or combinations of H and F; and

R^{IV} is:



wherein R^V is H, F or combinations of H and F.

53. The process of claim 50 wherein:

R'' is:

H;

F; or

CR'''₃

—Si—CR'''₃;

CR'''₃

wherein R''' is H, F or combinations of H and F; and

R^{IV} is:

H;

F; or

CR^V₃

CR^V₃—Si—

CR^V₃

wherein R^V is H, F or combinations of H and F; and

when R'' is H or F, R^{IV} is not H or F.

54. The process of claim 50 wherein:

R₁₋₃ are independently H or CH₃;

R₄₋₁₂ are each H;

R^{IV} is:

H

or

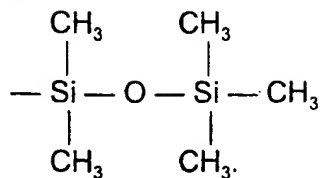
CH₃

CH₃—Si—

CH₃

and

R'' is:



55. The process of claim 50 wherein:

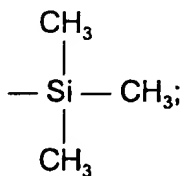
R₁₋₃ are independently H or CH₃;

R₄₋₁₂ are each H;

R'' is:

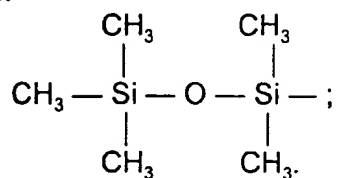
H

or



and

R^{IV} is:



56. The process of claim 50 wherein:

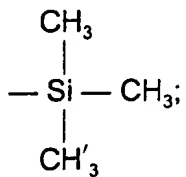
R₁₋₃ are independently H or CH₃;

R₄₋₁₂ are each H;

R'' is:

H;

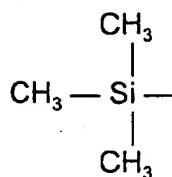
or



R^{IV} is:

H;

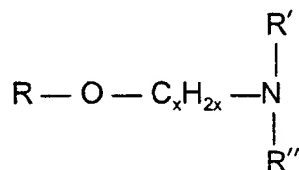
or



and when R'' is H, R^{IV} is not H.

57. A process for cleaning substrates comprising:
cleaning the substrates with an organic solvent; and
removing the organic solvent from the substrates using a pressurized fluid
solvent;

wherein the organic solvent is of the structural formula:



wherein R' is $H_j - (R''' - \begin{array}{c} R^{IV} \quad R^{IV} \\ | \quad | \\ C - C \\ | \quad | \\ R^{IV} \quad R^{IV} \end{array})_k -$ and

R'' is $H_j - (R''' - \begin{array}{c} R^{IV} \quad R^{IV} \\ | \quad | \\ C - C \\ | \quad | \\ R^{IV} \quad R^{IV} \end{array})_n -$

wherein R''' is O and j is 1 or R''' is N and j is 2;

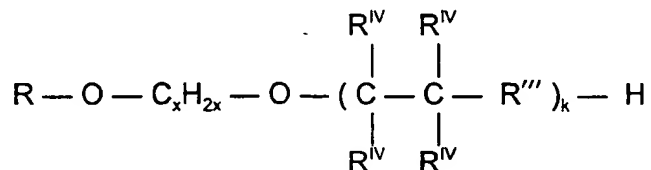
n is an integer between zero and two;

R^{IV} are each independently H, CH_3 or CH_2CH_3 and k is an integer
between zero and two inclusive; and

wherein R is $\text{C}_y\text{H}_{2y+1}$ and y is an integer between one and $(12 - (3k + 3n + x))$
inclusive, and x is an integer between one and $(12 - (3k + y))$, inclusive.

58. A process for cleaning substrates comprising:
 cleaning the substrates with an organic solvent; and
 removing the organic solvent from the substrates using a pressurized fluid
 solvent;

wherein the organic solvent is of the structural formula:



wherein R''' is O and j is 1 or R''' is N and j is 2;

R^{IV} are each independently H, CH_3 or CH_2CH_3 and k is an integer between zero and two inclusive; and

wherein R is C_yH_{2y+1} and y is an integer between one and $(12 - (3k+x))$ inclusive, and x is an integer between one and $(12 - (3k+y))$, inclusive.

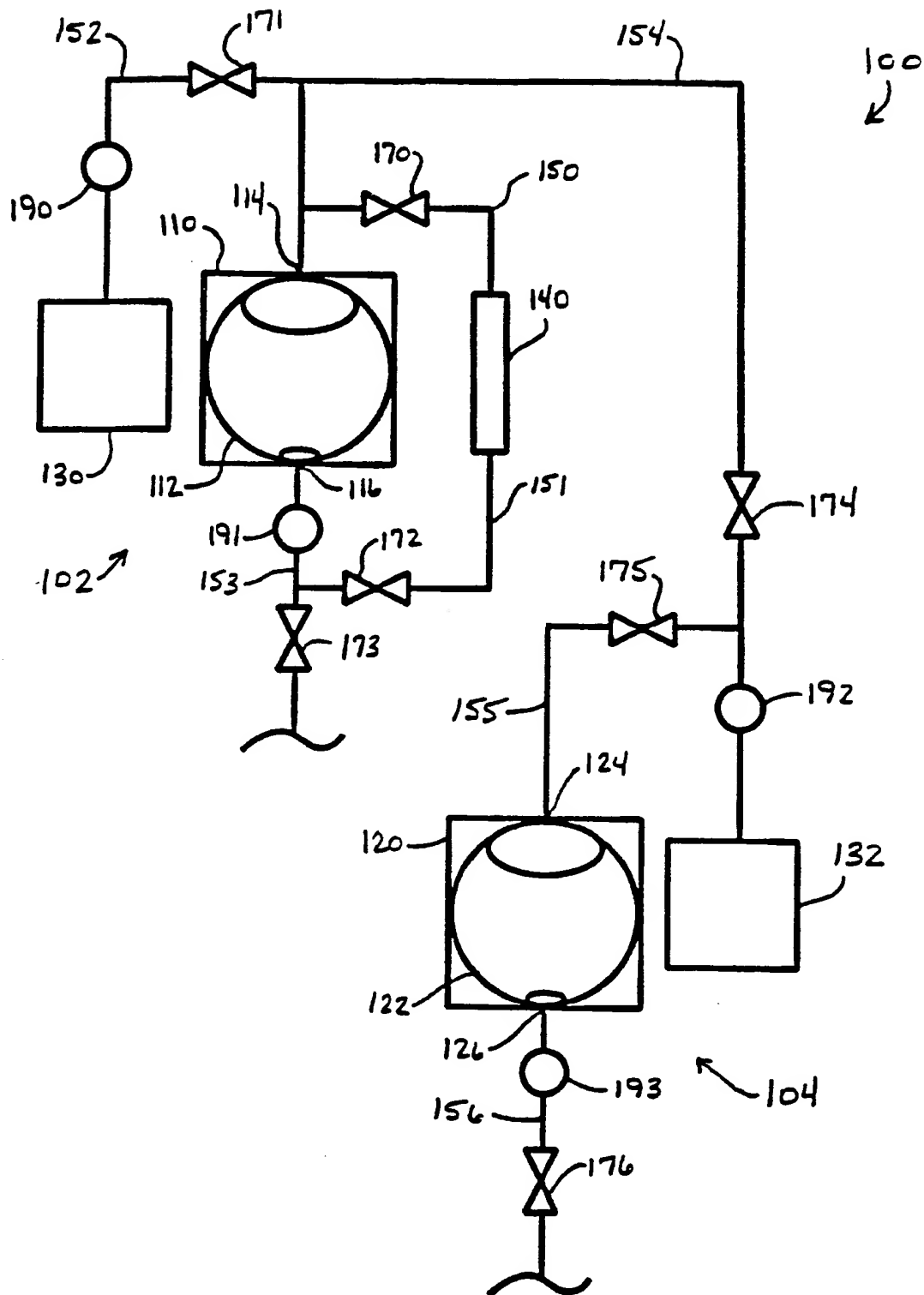


FIG. 1

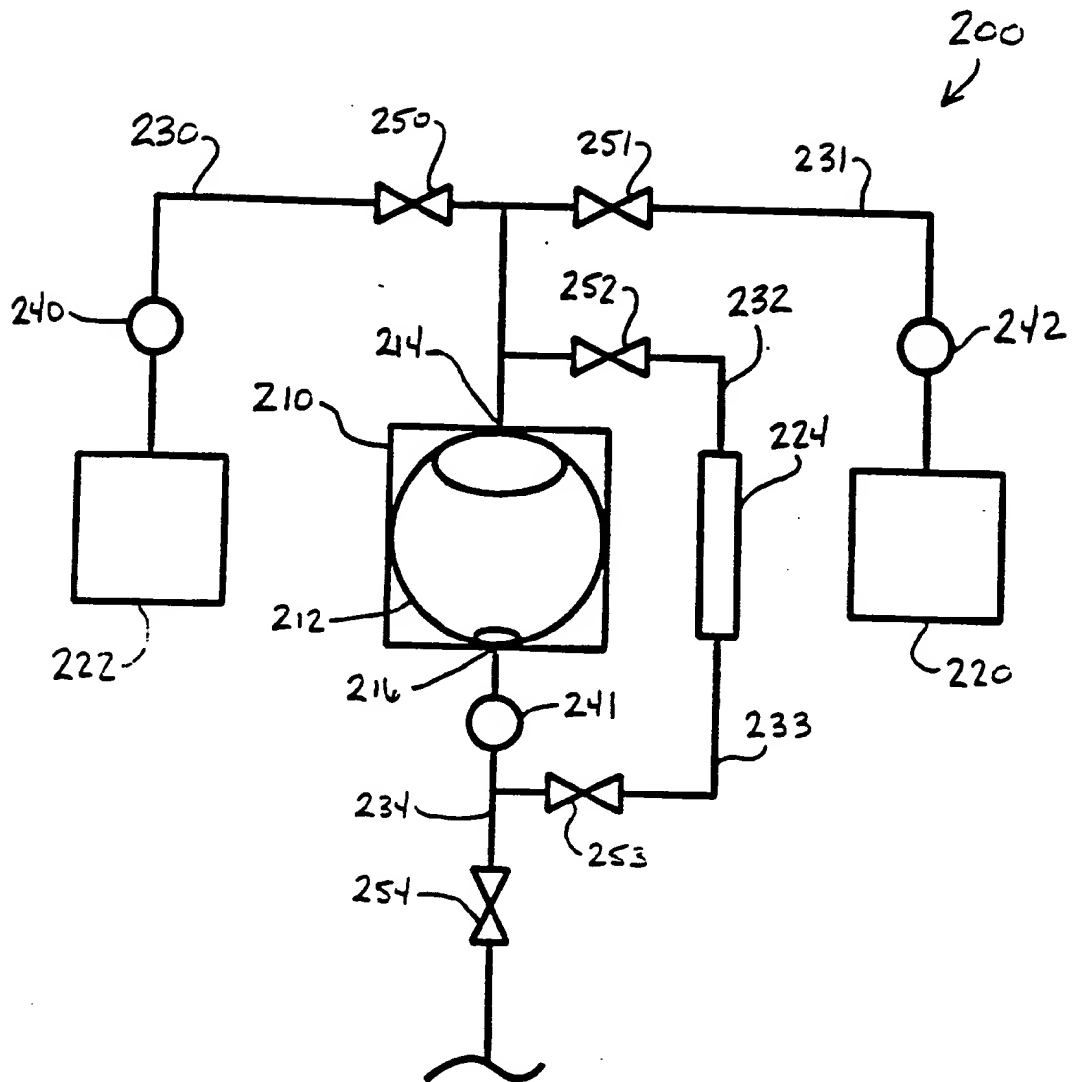


FIG. 2

INTERNATIONAL SEARCH REPORT

International Application No

PCT/US 00/28433

A. CLASSIFICATION OF SUBJECT MATTER
IPC 7 D06L1/02

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)

IPC 7 D06L

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practical, search terms used)

WPI Data, EPO-Internal, PAJ

C. DOCUMENTS CONSIDERED TO BE RELEVANT

| Category * | Citation of document, with indication, where appropriate, of the relevant passages | Relevant to claim No. |
|------------|---|-----------------------|
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| A | WO 94 01227 A (CLOROX CO) 20 January 1994 (1994-01-20) claims 1,5 --- | 1,2,50, 57,58 |
| A | US 5 888 250 A (BATES STEPHEN P ET AL) 30 March 1999 (1999-03-30) cited in the application abstract ----- | 1-58 |

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Further documents are listed in the continuation of box C.

☒

Patent family members are listed in annex.

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O document referring to an oral disclosure, use, exhibition or other means

P document published prior to the international filing date but later than the priority date claimed

T later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention

X document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone

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Date of the actual completion of the international search

26 January 2001

Date of mailing of the international search report

06/02/2001

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Authorized officer

Saunders, T

INTERNATIONAL SEARCH REPORT

Information on patent family members

International Application No

PCT/US 00/28433

| Patent document cited in search report | Publication date | Patent family member(s) | Publication date |
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